

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	26	(@ad<"20030623") and ((resist or mask or photoresist) with (("uv" or light) and hygroscopic))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 12:12
L2	5	(@ad<"20030623") and ("257"/\$.ccls. or "438"/\$.ccls.) and ((resist or photoresist) with (("uv" or light) and hygroscopic))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 12:15
L3	6	(@ad<"20030623") and (chip or die or semiconductor) and ((resist or photoresist) with (("uv" or light) and hygroscopic))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 12:15
L4	4	L3 not L2	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 12:15
L5	28144	(@ad<"20030623") and (chip or die or semiconductor or "257"/\$.ccls. or "438"/\$.ccls.) and ((resist or photoresist) with ("uv" or light))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:11
L6	3609	L5 and ((resist or photoresist) with (ethylene or glycol or glycerin or methyl or pyrrolidone or yttrium or neodymium or cerium or lanthanum or scandium or ceric or cerium or sulfate or nitrate or chloride or acetate or ammonium or hydroxide or octylate))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 12:49
L7	226	L6 and (hygroscopic or rare or earth)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 12:56

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L8	415	L5 and ((resist or photoresist) with (((ethylene or polyethylene) adj glycol) or ((glycerin or methyl) near pyrrolidone) or ((yttrium or neodymium or cerium or lanthanum or scandium) near oxide) or ((ceric or ammonium) near sulfate) or ((cerium or ammonium or lathanum) near nitrate) or (cerium adj (acetate or chloride or hydroxide or oxtylate))))))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:09
L9	18	L8 and (hygroscopic or rare or earth)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 12:56
L10	17	L9 and (water or moisture or "h.sub.2 O")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:00
L11	493	(Negative with (photoresist or resist)) and ((resist or photoresist) with (((ethylene or polyethylene) adj glycol) or ((glycerin or methyl) near pyrrolidone) or ((yttrium or neodymium or cerium or lanthanum or scandium) near oxide) or ((ceric or ammonium) near sulfate) or ((cerium or ammonium or lathanum) near nitrate) or (cerium adj (acetate or chloride or hydroxide or oxtylate))))))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:33
L12	354	L11 and (@ad<"20030623") and ("uv" or light)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:34
L13	351	L11 and (@ad<"20030623") and ("uv" or light) and (moisture or water or solvent or bath or wash or spray or drench or solute or solution)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:16

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L14	234	L11 and (@ad<"20030623") and ("uv" or light) same (moisture or water or solvent or bath or wash or spray or drench or solute or solution or "h.sub.20" or "h.sub.2 0"))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:34
L15	653	"430"/\$.ccls. and (photoresist or resist) and ((resist or photoresist) with (((ethylene or polyethylene) adj glycol) or ((glycerin or methyl) near pyrrolidone) or ((yttrium or neodymium or cerium or lanthanum or scandium) near oxide) or ((ceric or ammonium) near sulfate) or ((cerium or ammonium or lathanum) near nitrate) or (cerium adj (acetate or chloride or hydroxide or oxylyate))))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:14
L16	456	L15 and (@ad<"20030623") and ("uv" or light) and (moisture or water or solvent or bath or wash or spray or drench or solute or solution)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:16
L17	325	L16 and (chip or die or semiconductor)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:17
L18	417	L16 and (chip or die or semiconductor or silicon)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:17
L19	456	L18 or L16	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:28
L20	1	("20040259008").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/01/26 13:29

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L21	711	(positive with (photoresist or resist)) and ((resist or photoresist) with (((ethylene or polyethylene) adj glycol) or ((glycerin or methyl) near pyrrolidone) or ((yttrium or neodymium or cerium or lanthanum or scandium) near oxide) or ((ceric or ammonium) near sulfate) or ((cerium or ammonium or lathanum) near nitrate) or (cerium adj (acetate or chloride or hydroxide or oxytlate))))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:33
L22	470	L21 and (@ad<"20030623") and ("uv" or light)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:34
L23	303	L22 and (@ad<"20030623") and (("uv" or light) same (moisture or water or solvent or bath or wash or spray or drench or solute or solution or "h.sub.20" or "h.sub.2 0"))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:35
L24	2102169	l18 or l14 or "123"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:35
L25	515	l18 or l14 or L23	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/01/26 13:35